



# Use of the MPPCs for the Mu2e e.m. calorimeter

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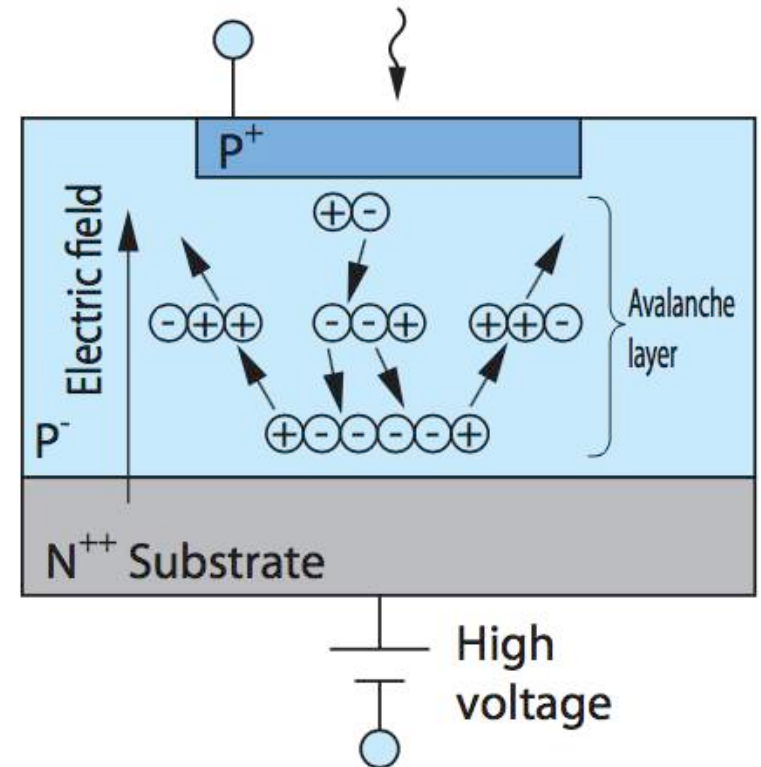
# Talk Layout

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- Silicon Photo Multiplier
  - Introduction
  
- The Mu2e experiment
  - The Mu2e e.m calorimeter
  
- MPPC for the Mu2e calorimeter
  - Test Beam
  - MPPC vs neutrons flux / photons dose
  - Custom Device and First Tests

# APD

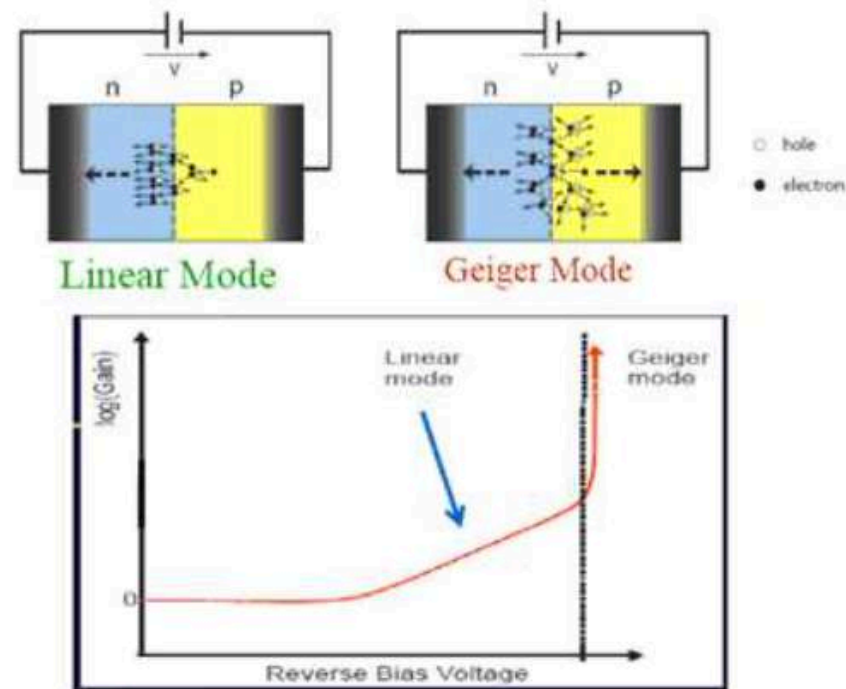
- 1) A photon absorbed in the depletion region produces a new electron-hole pair;
- 2) The electron-hole pair is accelerated by the high electric field **generating further electron-hole pairs**;
- 3) An Avalanche multiplication happens with a Gain proportional to the applied reverse bias voltage ( $G \sim 100-500$ ).



# I-V curve → SiPM

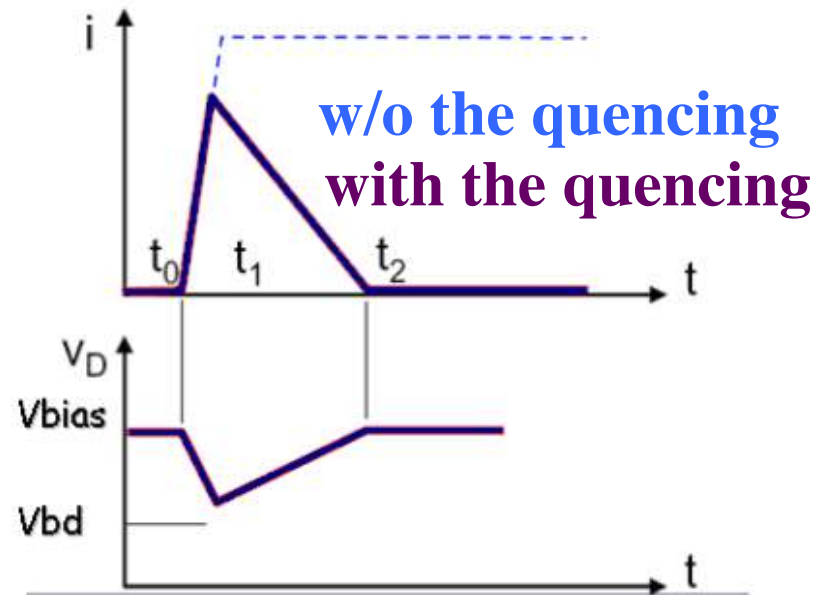
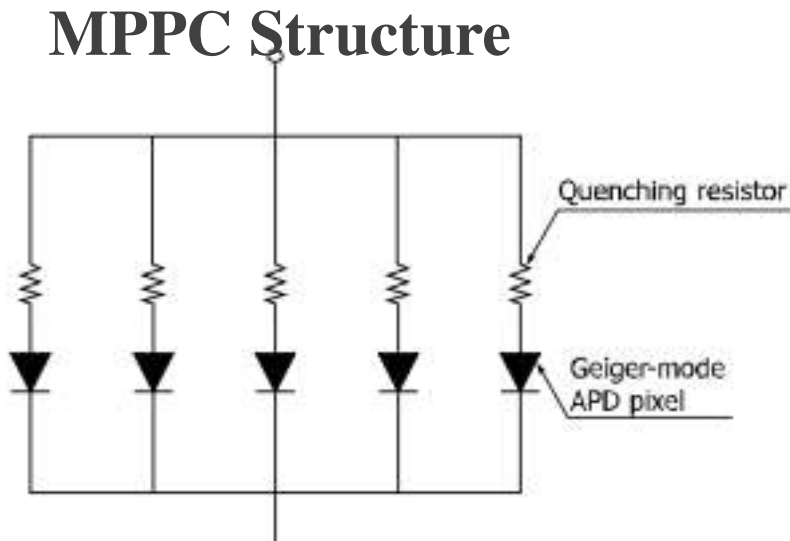
When the reverse voltage applied to an APD is set higher than the breakdown voltage, the electric field in the APD becomes high enough to cause a discharge (Geiger discharge) even by input of one single photon.

- The Geiger mode allows obtaining a large output by way of the discharge even when detecting a single photon. **Once the Geiger discharge begins, it continues as long as the electric field in the APD is maintained.**



# Quenching resistor

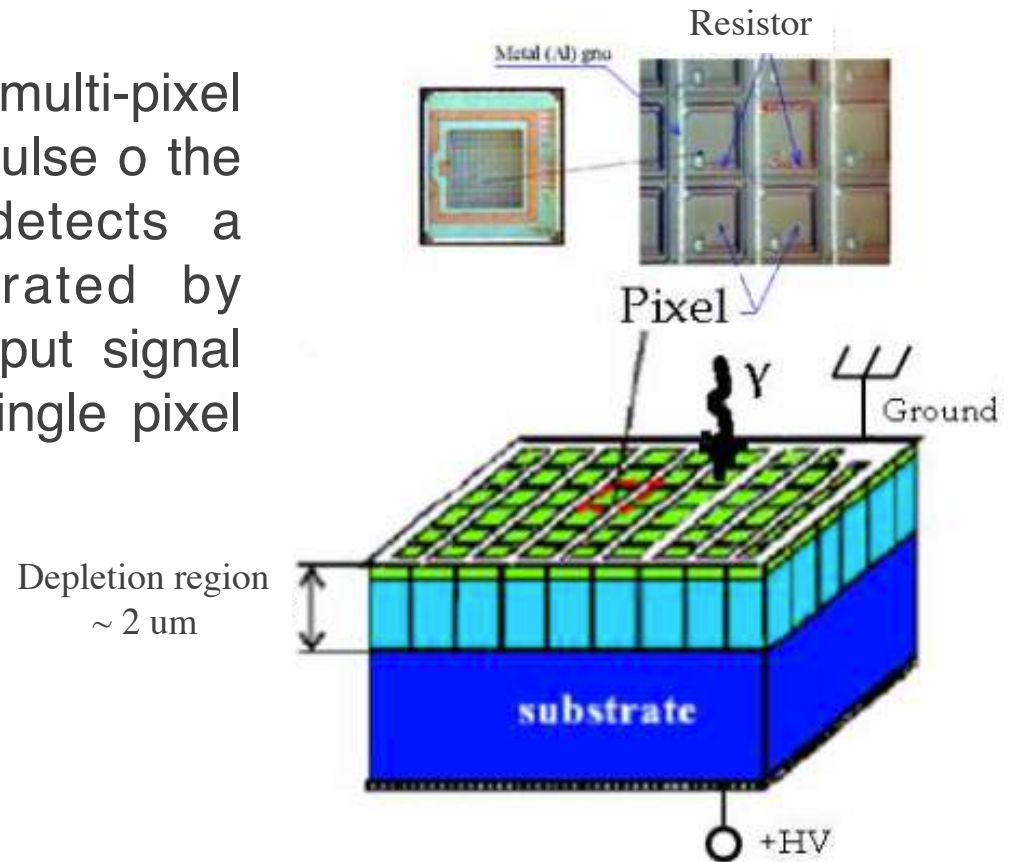
One specific example to stop the Geiger discharge is a technique using a so-called quenching resistor connected in series with the APD. This quickly stops avalanche multiplication in the APD because **a drop in the operating voltage occurs when the output current, caused by the Geiger discharge, flows.**



# Basic operation

The basic element (pixel) of an **MPPC** is a combination of the **Geiger mode APD** and **quenching resistor**, and a large number of these pixels are electrically connected and arranged in two dimensions;

- Each pixel in the MPPC (multi-pixel photon counter) generates a pulse of the same amplitude when it detects a photon. The pulses generated by multiple pixels create the output signal as a superimposition of the single pixel pulses.

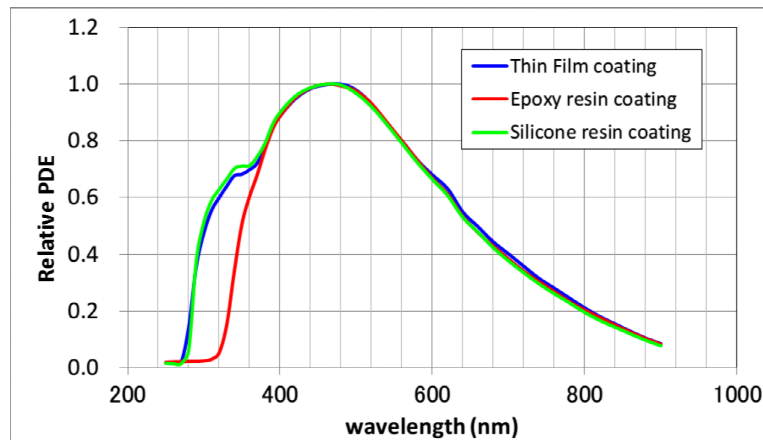


# PDE

The photon detection efficiency is the product of 3 components:

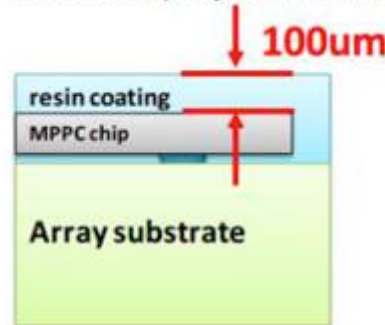
- 1) The quantum efficiency @ the silicon surface
- 2) The “filling factor” of active area with respect to the total area of the MPPC
- 3) The avalanche probability (that is function of  $V_{\text{bias}}$ )

## PDE comparison



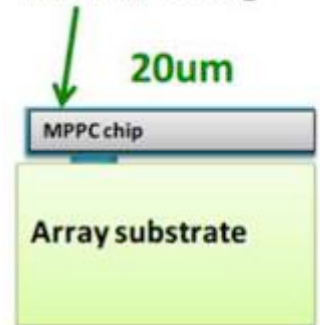
Thin Film coating and Silicon resin coating has PDE advantage in UV region.

Silicone, Epoxy resin coating



- merit
  - robust to the mechanical shock
  - easy handling (during assy.)
  - superior transparency in UV region
    - silicone resin coating type -

Thin Film coating



- merit
  - tough coating
    - (mechanical shock should be avoided)
  - superior transparency in UV region
  - cross-talk suppression in the coating
  - super flatness (minimum bending)

# Phototube vs SiPM

Vbias ~ kV



Vbias ~ 30-70 V



Gain ~ $10^6$



Gain ~ $10^6$



QE ~ 30%



PDE ~ 40%



No able to work  
in high magnetic  
field



Able to work in  
high magnetic  
field



Proportional  
response



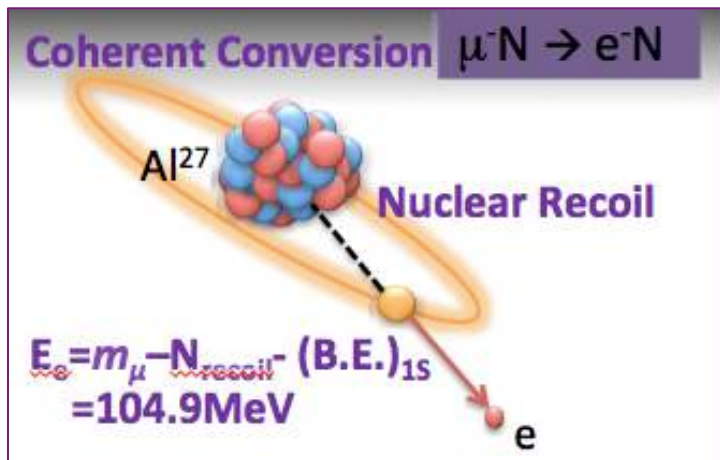
Digital devices,  
saturation  
problem





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# The Mu2e experiment



Detect the CLFV process  $\mu^- + (A,Z) \rightarrow e^- + (A,Z)$  i.e. the coherent, neutrinoless **conversion of a muon to an electron** in the field of a nucleus.

## ➤ Goal of Mu2e:

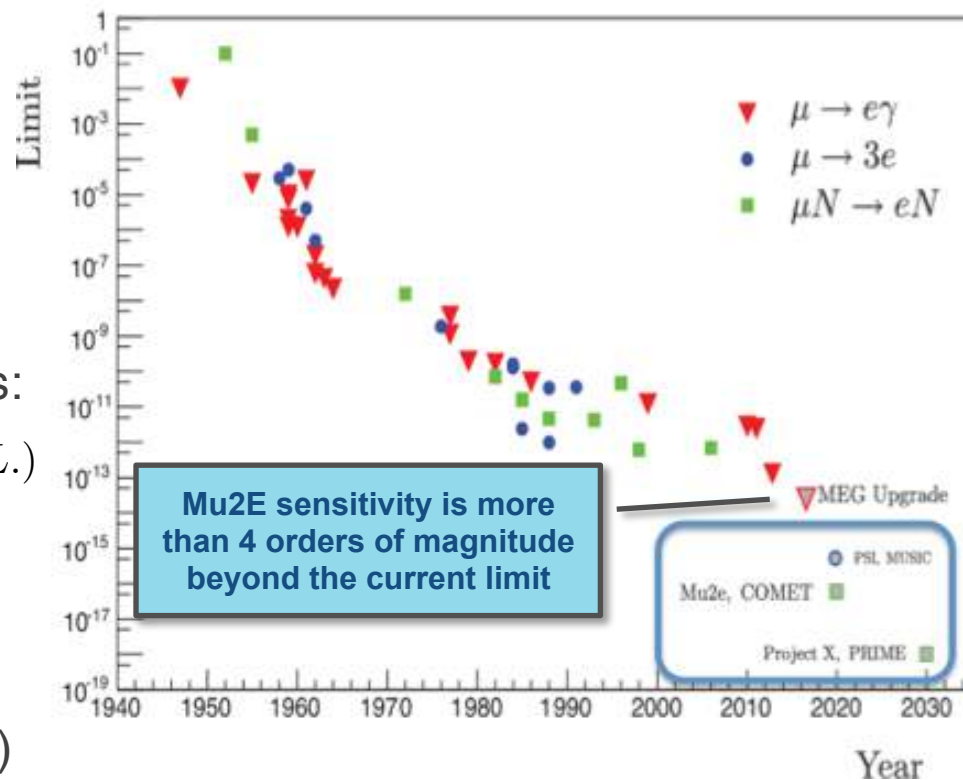
Measure the rate of conversion relative to ordinary muon capture on the nucleus:

$$R_{\mu e} = \frac{\mu^- Al \rightarrow e^- Al}{\mu^- Al \rightarrow capture} < 6 \times 10^{-17} \text{ (90\% C.L.)}$$

with a single event sensitivity (SES) of  $2.5 \times 10^{-17}$

## ➤ Current limits (SINDRUM II at PSI) :

$$R_{me} < 4.3 \times 10^{-12} \text{ (Ti)}, R_{me} < 7 \times 10^{-13} \text{ (Au)}$$



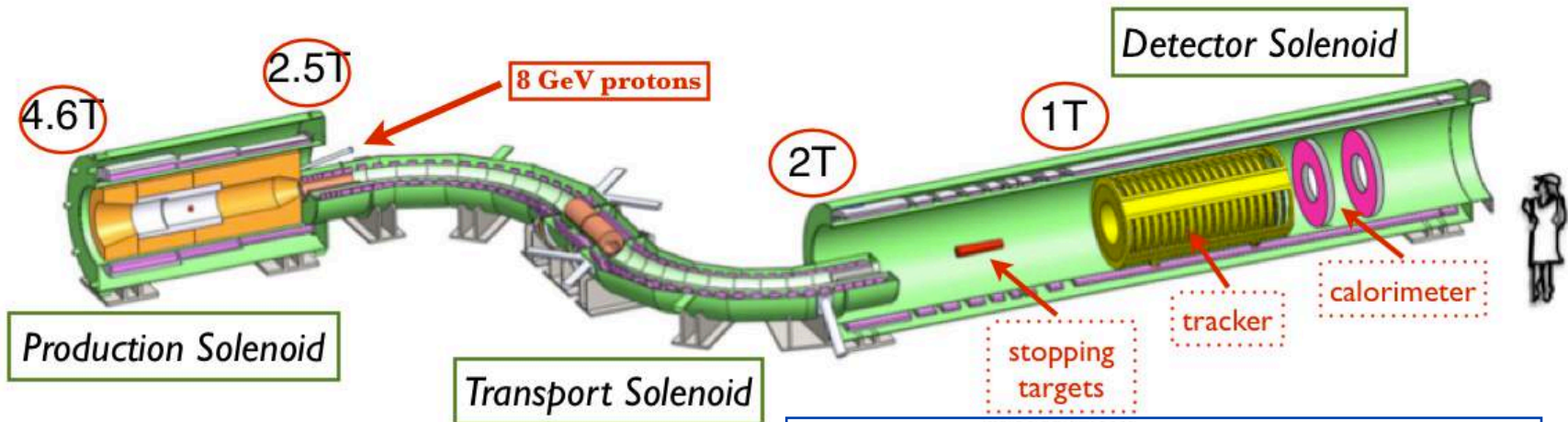
# The Mu2e experiment layout

- *Production Solenoid:*

- ➔ Proton beam strikes target, producing mostly pions
- ➔ Graded magnetic field contains backwards pions/muons and reflects slow forward pions/muons

- *Detector Solenoid:*

- ➔ Capture muons on Al target
- ➔ Measure momentum in tracker and energy in calorimeter
- ➔ Graded field “reflects” downstream conversion electrons emitted upstream



- *Transport Solenoid:*

- ➔ Select low momentum, negative muons
- ➔ Antiproton absorber in the mid-section

- *Targets:*

- ❖ 17 Al foils; Aluminum was selected mainly for the muon lifetime in capture events (864 ns) that matches nicely the need of prompt separation in the Mu2e beam structure.

- *Tracker:*

- ❖ ~25000 tubes arranged in planes on stations, the tracker has 18 stations
- ❖ Expected momentum resolution  $\sim 120 \text{ keV}/c$

# Physics and Calorimeter Requirements

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The Calorimeter should:

- Provide high  $e^-$  reconstruction efficiency for  $\mu$  rejection of 200
- Provide cluster-based seeding for track finding
- Provide online software trigger capability
- Survive in the radiation environment of Mu2e
- Operate for 1 year w.o. interruption in DS w/o reducing performance

**In order to do so the calorimeter should have the following capability**

- Provide energy resolution  $\sigma_E/E$  of O(5 %) @ 100 MeV
- Provide timing resolution  $\sigma(t) < 500$  ps
- Provide position resolution  $< 1$  cm
- Redundancy in FEE and photo-sensors

**Solution: A crystal based disk calorimeter**

# Derived requirements

## High granularity crystal based calorimeter with:

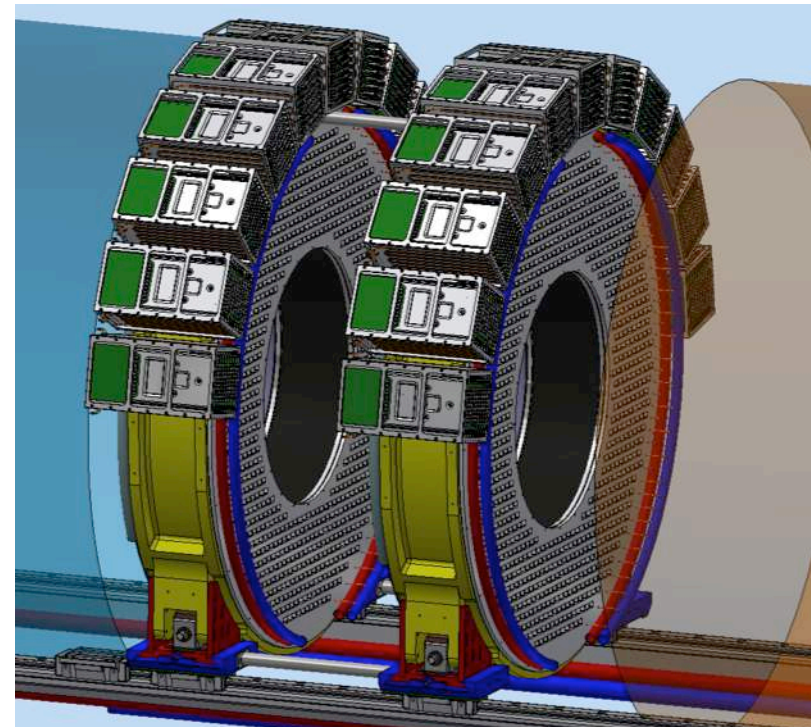
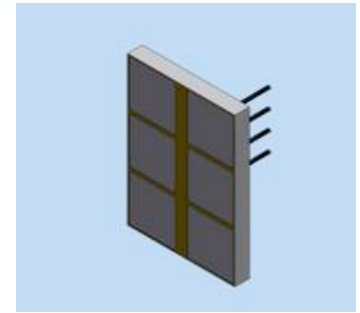
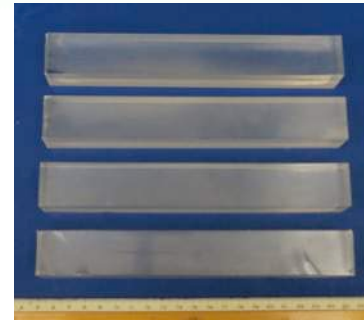
- ❑ 2 Disks (Anuli) geometry to optimize acceptance for spiraling electrons
- ❑ Crystals with high Light Yield for timing/energy resolution  
→ **LY(photosensors) > 20 pe/MeV**
- ❑ **2 photo-sensors/preamps/crystal** for redundancy  
and reduce MTTF requirement → now set to 1 million hours/SIPM
- ❑ Fast signal for Pileup and Timing resolution →  **$\tau$  of emission < 30 ns**
- ❑ **Crystal dimension optimized** to stay inside DS envelope  
→ reduce number of photo-sensor, FEE, WFD (cost and bandwidth)  
while keeping pileup under control and position resolution < 1 cm.
- ❑ Crystals and sensors should work in 1 T B-field and in vacuum of  $10^{-4}$  Torr and:  
→ **Crystals survive a dose of 100 krad and a neutron fluency of  $10^{12}$  n/cm<sup>2</sup>**  
→ **Photo-sensors survive 20 krad a neutron fluency of  $3 \times 10^{11}$  n\_1MeV/cm<sup>2</sup>**

Safety  
Factor = 3

# Calorimeter Design

**The Calorimeter consists of two disks with 674 CsI square crystals:**

- $R_{\text{inner}} = 374 \text{ mm}$ ,  $R_{\text{outer}} = 660 \text{ mm}$ , depth =  $10 X_0$  (200 mm)
- Each crystal is readout by two large area UV extended SiPM's ( $14 \times 20 \text{ mm}^2$ )
- Analog FEE is on the SiPM and digital electronics located in near-by electronics crates
- Radioactive source and laser system provide absolute calibration and monitoring capability



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# Requirements

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Photosensors must meet the following requirements:

- (R1) Have a high quantum efficiency @ 315 nm (the emission peak for CsI) and a large active area to maximize the number of collected photoelectrons;
- (R2) Have a high gain, fast signal and low noise (MeV equivalent);
- (R3) withstand a radiation environment of  $3 \times 10^{11}$  n/cm<sup>2</sup> @ 1 MeV<sub>eq</sub> and 20 krad for photons;
- (R4) Work in vacuum at  $10^{-4}$  Torr;
- (R5) Have sufficient reliability to allow operation for 1 year w.o. interruption;
- (R6) Allow replacement of photosensors after 1 year of running if needed



# UV-extended SiPM – Hamamatsu

We started testing arrays of 16  $3 \times 3 \text{ mm}^2$  Hamamatsu TSV MPPCs ( $12 \times 12 \text{ mm}^2$ )

- These have silicone and thin film protection layers
- SiPMs coupled to pure CsI crystals ( $30 \times 30 \times 200 \text{ mm}^3$ )

✓ A first matrix prototype has been built to test it @ the electron beam test facility (BTF) of Frascati (7-12 of April 2015).

The prototype consists of a **MATRIX** of 9 pure CsI crystals ( $30 \times 30 \times 200 \text{ mm}^3$ ):

- 2 CsI by Optomaterial (Sardegna, Italy)
- 7 pure CsI by ISMA (Kharkov, Ukraine)
- All crystals shown a good uniformity LRU ( $< 10 \%$ ) when wrapped with Tyvek and optically coupled to photosensors with Bluesil Past-7 silicon grease

Each crystal is readout by one  $12 \times 12 \text{ mm}^2$  **SPL MPPCs** UV enhanced from Hamamatsu



# Matrix assembly: components

100  $\mu\text{m}$  Tyvek reflective wrapping



MPPC lodgments created by means of PVC 3D print

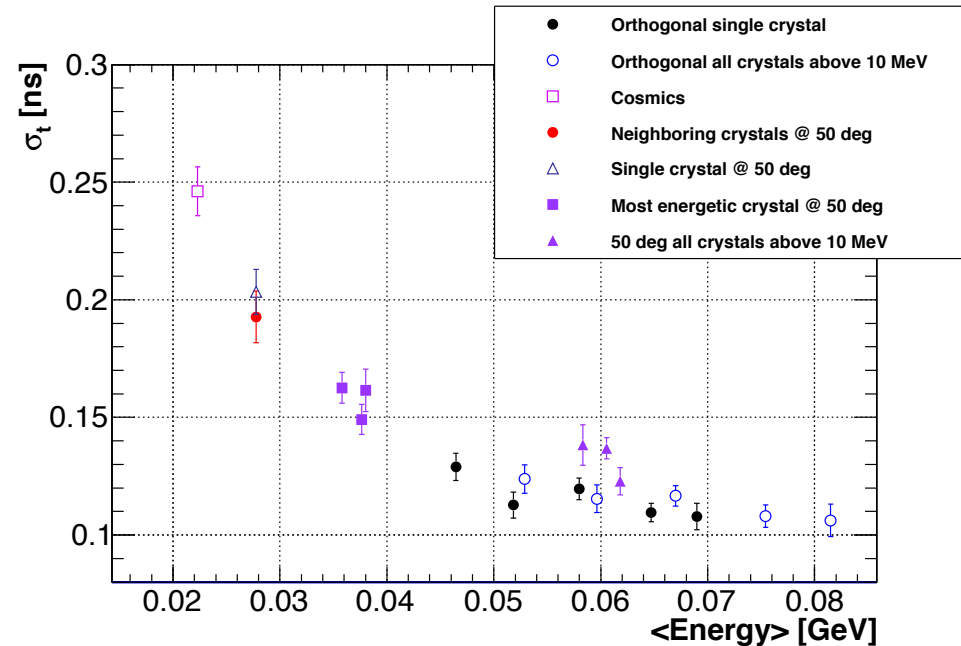
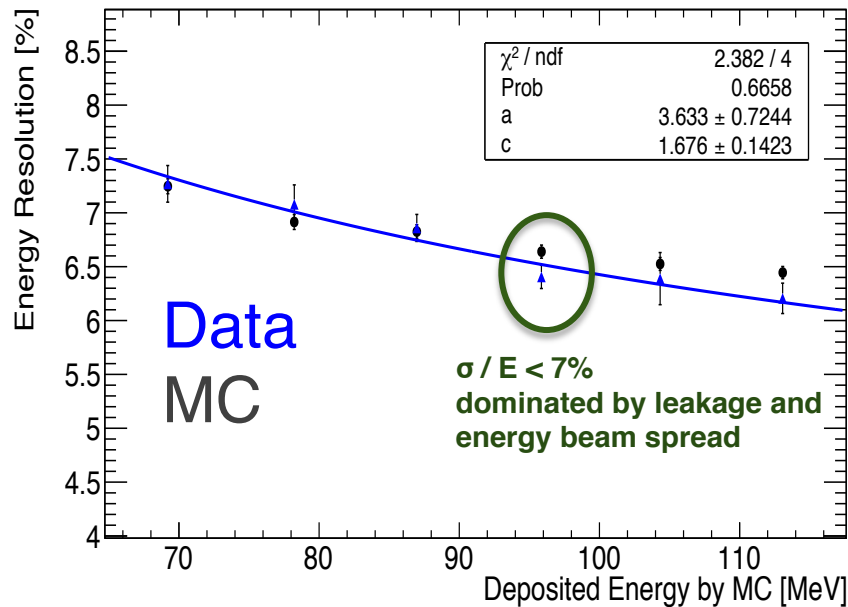


Electronics FEE: analog adder of the 16 anodes/MPPC



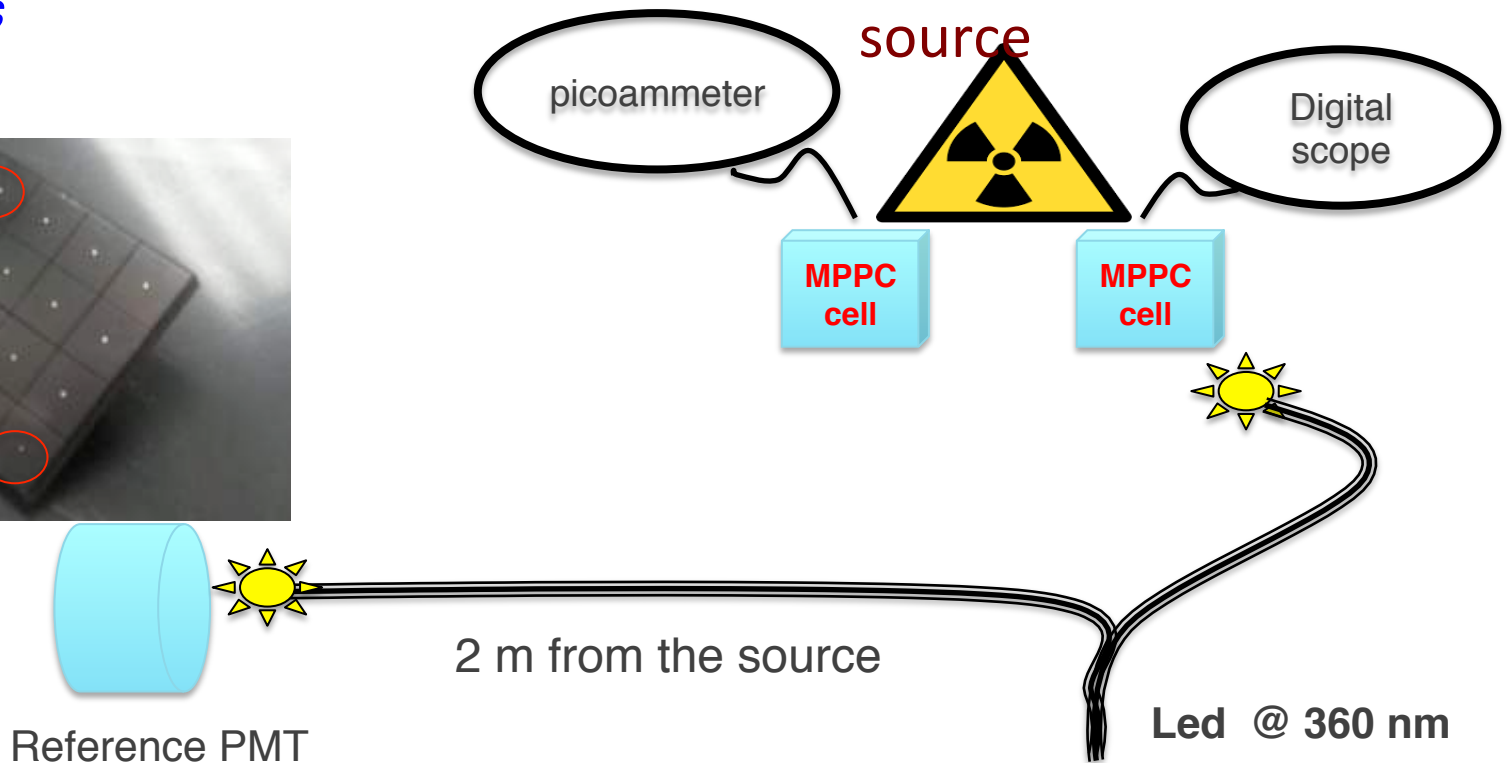
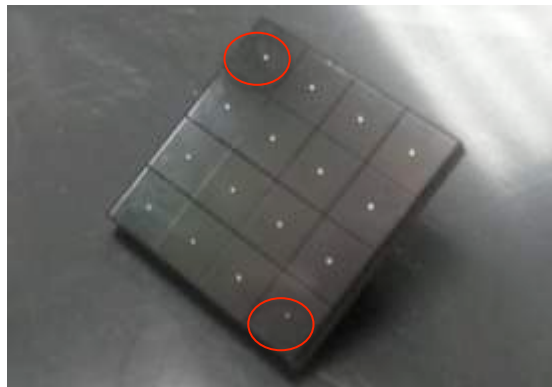
# Results

- ~ 30 (20) p.e/MeV with (without) optical grease with Tyvek-wrapped crystals
- Time resolution < 150 ps @ 100 MeV with 45° e impact angle
- Energy resolution better than 7% at 100 MeV (leakage dominated)
- Equivalent noise ~ 100 keV



# (R3) → Irradiation test of MPPC and SiPM

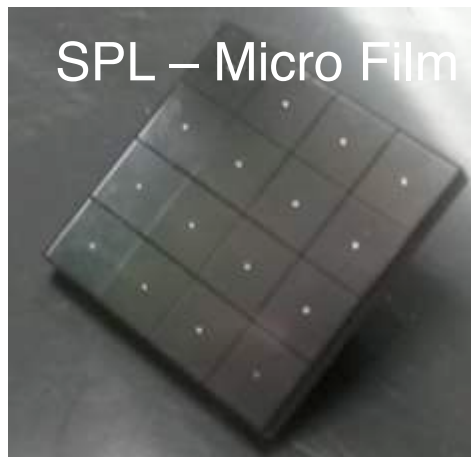
- We have tested the radiation response of the SPL and Thin Film MPPCs:
  - 1) with neutron @ Frascati Neutron Generator (FNG)
  - 2) with photons @ Enea Casaccia
- Measurement of response and leakage current
- Also 6x6 mm<sup>2</sup> of UV extended SiPM from FBK have been tested with neutrons



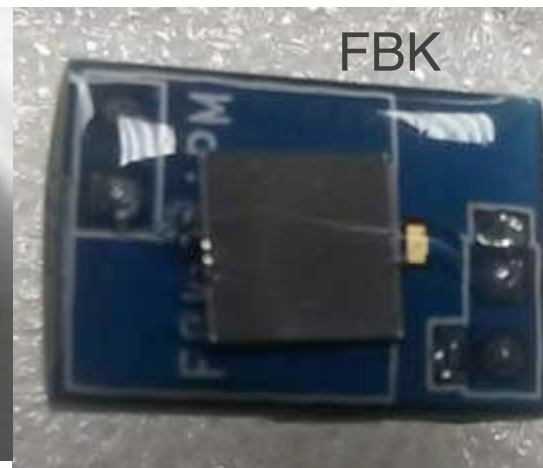
# (R3) – Irradiation with neutrons (1)

- SiPM irradiated @ FNG (Frascati) with 14 MeV neutrons in October 2015.
- Total flux delivered in less than 4 hours
- Out of 16 MPPC cells:
  - 1 cell used for leakage current
  - Another cell used for response to a fixed UV LED pulse;
  - PMT used as reference for the light input.
- For the monolithic FBK we have measured only the leakage current

	V op (V)	Total flux (n/cm <sup>2</sup> )	Total flux (n_1MeV/cm <sup>2</sup> )
SPL 4 SiPM	53.9	2.2 x 10 <sup>11</sup>	4 x 10 <sup>11</sup>
Micro Film SiPM	53.95	2.2 x 10 <sup>11</sup>	4 x 10 <sup>11</sup>
FBK SiPM	32.5	2.2 x 10 <sup>11</sup>	4 x 10 <sup>11</sup>

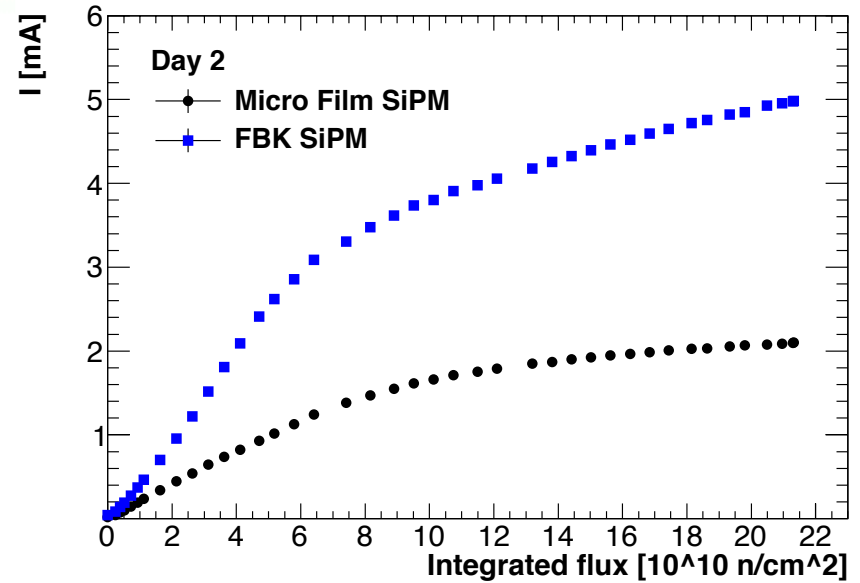
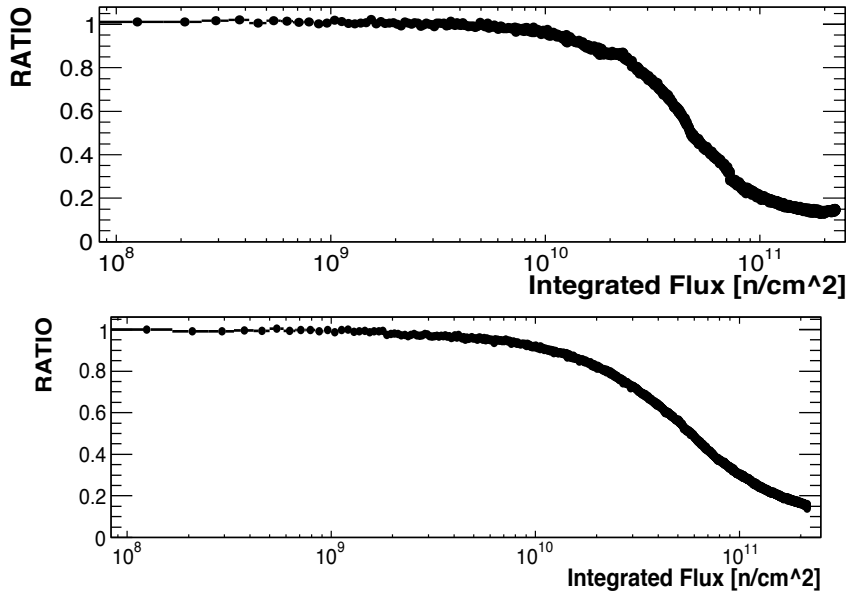


16 MPPC of 3x3 mm<sup>2</sup>



1 SiPM of 6x6 mm<sup>2</sup>

# (R3) – Irradiation with neutrons (2)



For a neutron fluence equivalent to 2.2 times the experiment lifetime, the signal peak decreases from:

- ~250 to 30 mV for SPL
- ~400 mV to 50 mV for TF

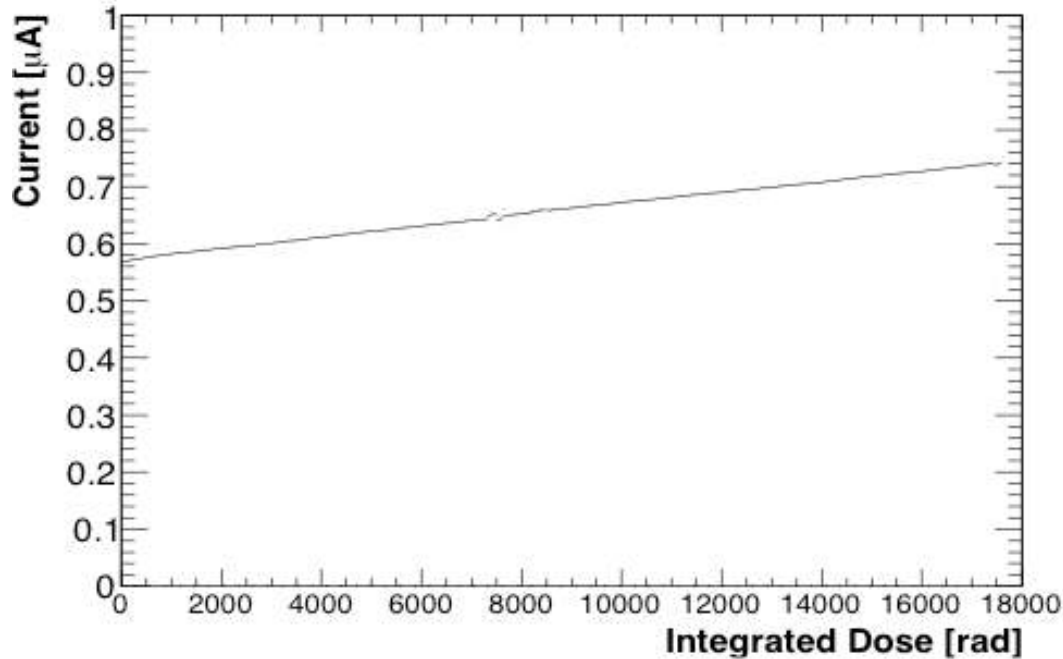
For the innermost layer a larger amplification value can be used (e.g. from 10 to 20)

Reported current for FBK SiPM has been **corrected by a factor of 4**, due to the different active area.

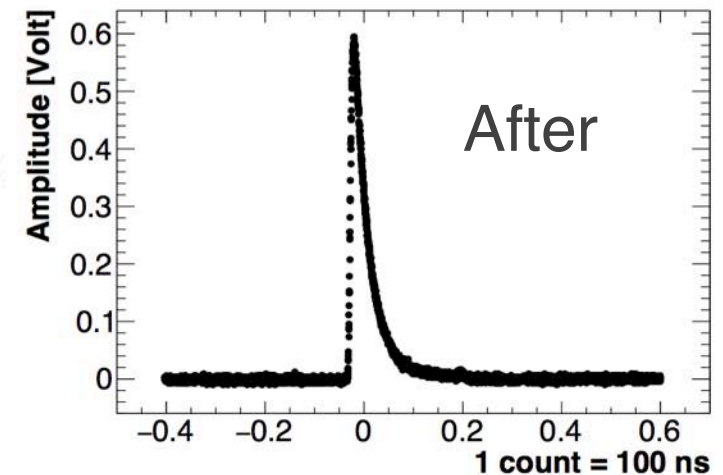
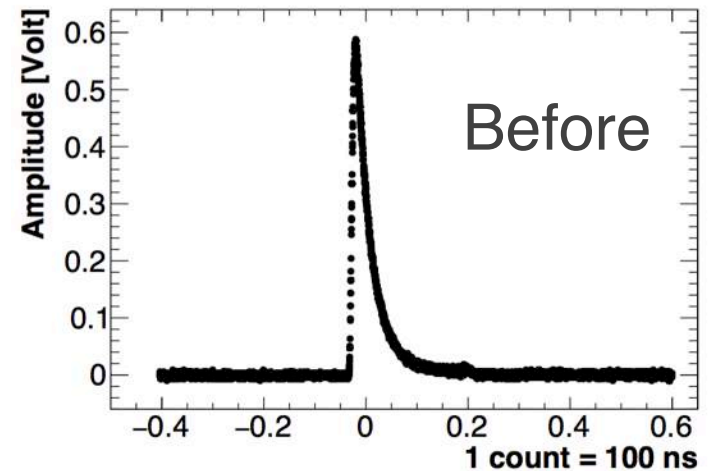
- The current increased from
- **16 uA up to 2 mA (TF)**
  - **100 uA up to 2.2 mA (SPL)**
  - **86/4 uA up to 19/4 ~5 mA (FBK)**

# (R3) – Irradiation with photons

We have irradiated the photosensor at ENEA Casaccia with an high intensity  $^{60}\text{Co}$  source up to 20 krad (200 Gy)

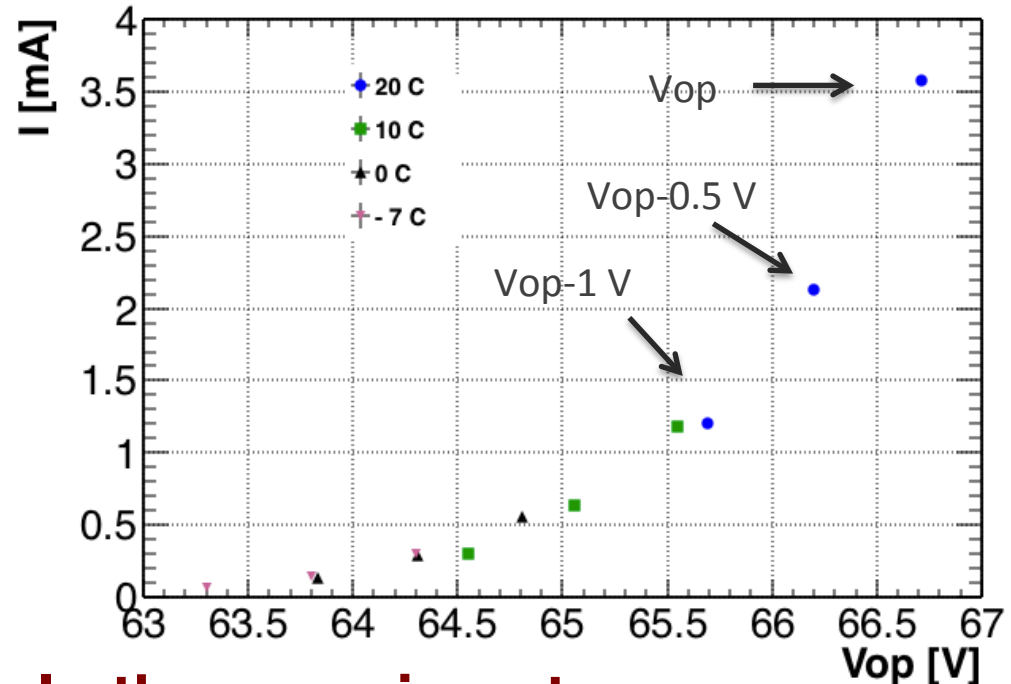


Negligible effect on the response and on the leakage current due to the dose



# (R3) - Leakage Current vs Temperature and $V_{bias}$

- We have measured the leakage current of the MPPCs changing the temperature and three different set of  $V_{bias}$ :  $V_{op}$ ,  $V_{op}-0.5$ ,  $V_{op}-1$  Volt
- Measurement in Vacuum with micro TEC peltier and PT1000 sensor.
- The data are related to a single cell (6x6 mm<sup>2</sup>).

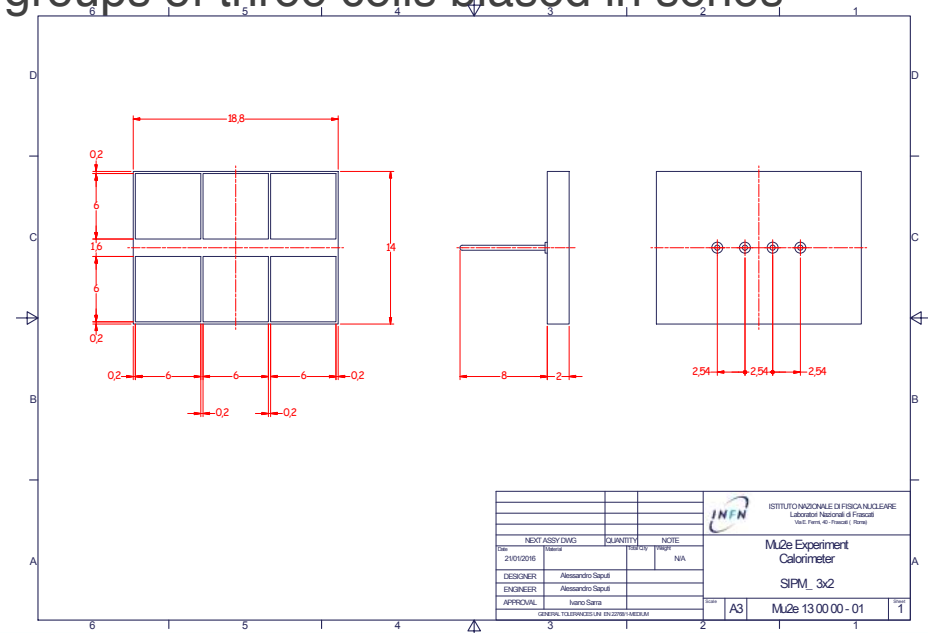
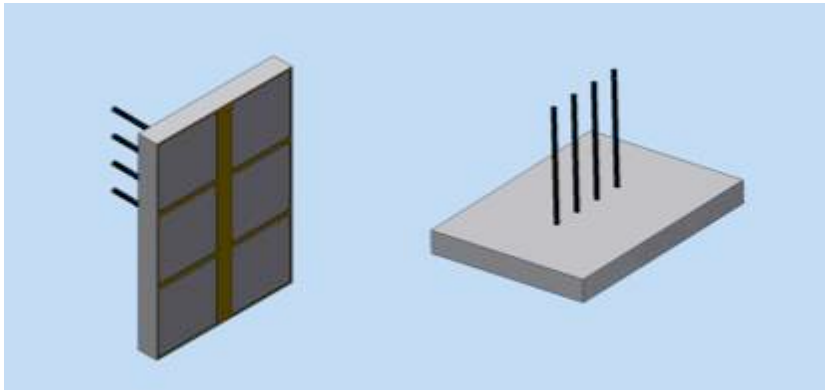


**In the experiment,  
the Photosensors will be kept @ 0°C**

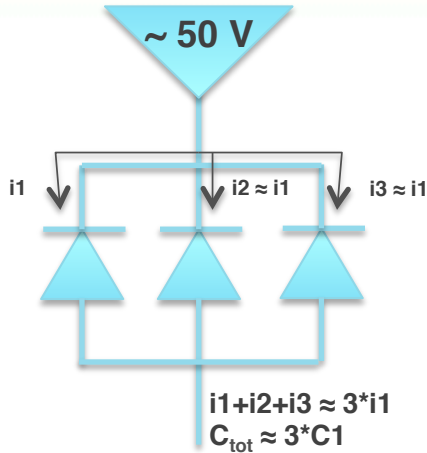


# Mu2e Photosensor will be a custom SiPM

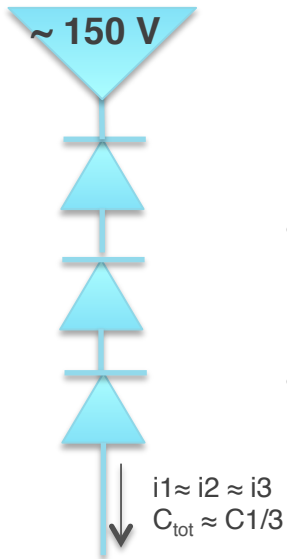
- We have chosen a modular SiPM layout that allows us to enlarge the active area, maximizing the number of collected photoelectrons.
- The crystal dimension, increased from 30x30 to 34x34 mm<sup>2</sup>, accommodates a 2x3 array of individual 6x6 mm<sup>2</sup> SiPM modules
- This allows us to work use an air-gap while satisfying the p.e./MeV requirement with a single photosensor, although two are used for redundancy
- The SiPM will be made of a 2x3 matrix (6 cells) of 6x6 mm<sup>2</sup> UV extended SiPMs
- We use a parallel arrangement of two groups of three cells biased in series



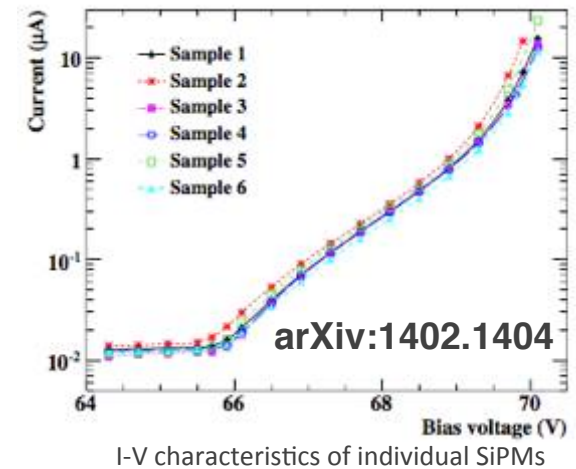
# Series vs Parallel polarizations



	Parallel	Series
Total Bias (Volt)	😊	😞
Total Current (A)	😞	😊
Power (Watt)	😐	😐
Total Capacitance	😞	😊
Decay Time	😞	😊



While the individual breakdown voltages differ by a few hundred millivolts, the shapes of the I-V curves are quite similar.



- Decay time can be regulated at the shaping level, but a high detector capacitance increases noise (worsens the signal-to-noise ratio)
- When SiPMs are connected in series, the voltage applied to each SiPM is determined by the common leakage current. Then, the difference in breakdown voltages is absorbed, and the over-voltages are approximately aligned.

# 2x3 SipM array performance

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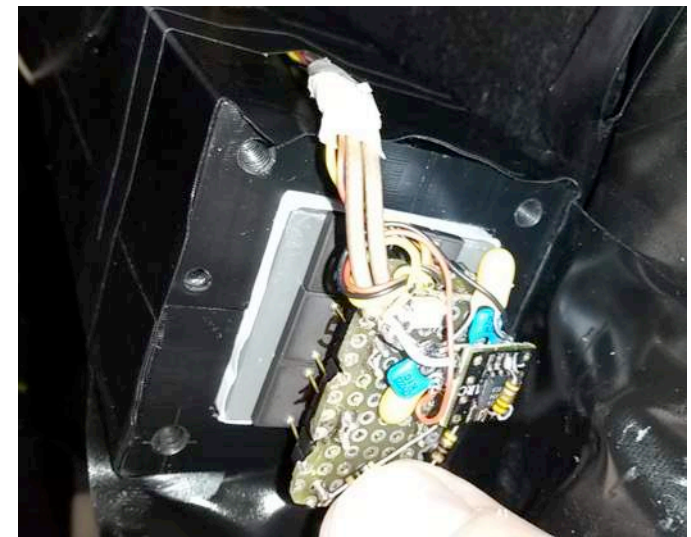
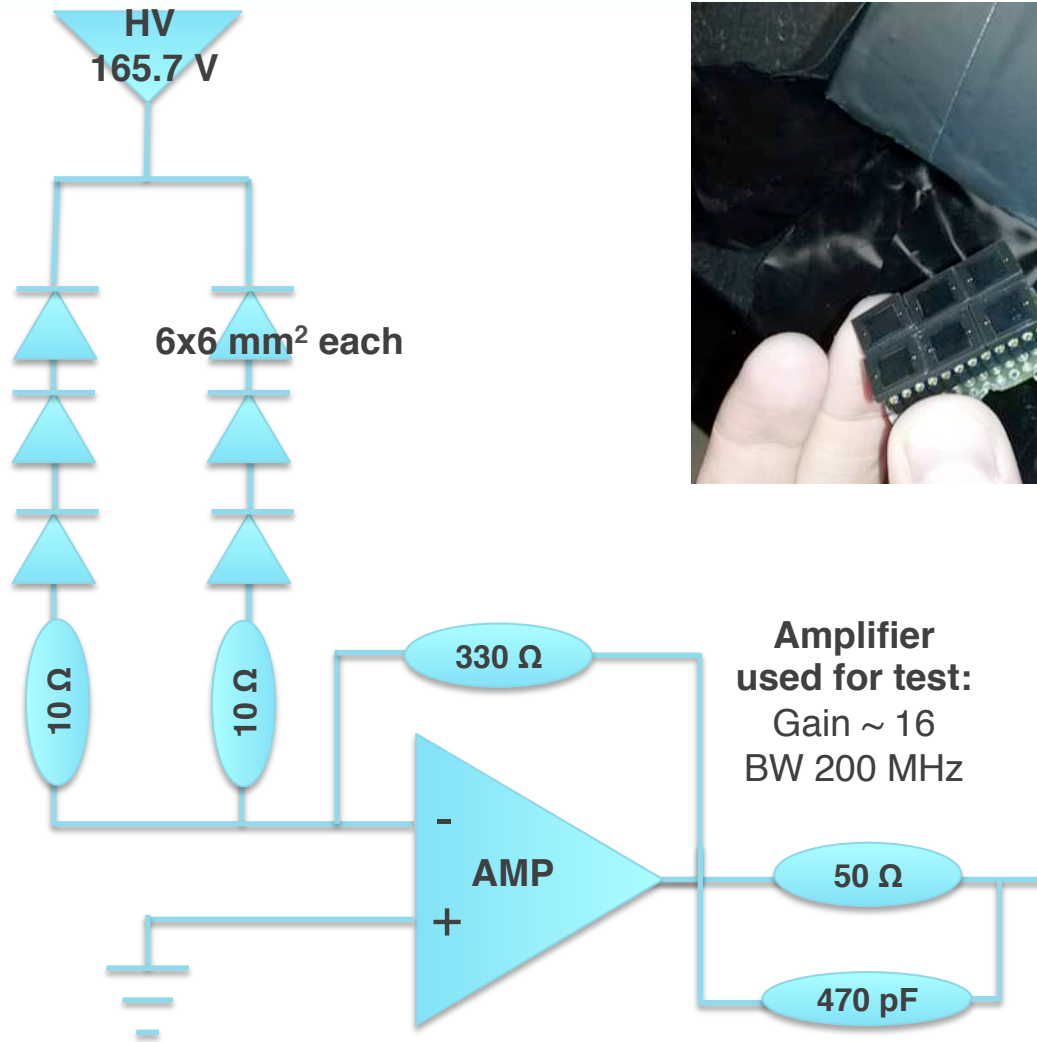
**We have already received 7 monolithic MPPCs of 6x6 mm<sup>2</sup> dimensions**  
→ 6 of them have been used to build a 2x3 array with our packaging.  
→ UV extended by SPL technique

**Goal:** Evaluate the quenching time, the equivalent capacitance, the gain and the PDE.

Specifications:

- PDE ~ 30% @ 315 nm;
- Gain > 10<sup>6</sup> at  $V_{op} = V_{br} + 3V$
- the series connection of the three 6x6 mm<sup>2</sup> SiPMs should produce a signal width of about 70 ns ( $\tau \sim 15$  ns) to minimize pileup

# Polarization scheme



# Experimental setup

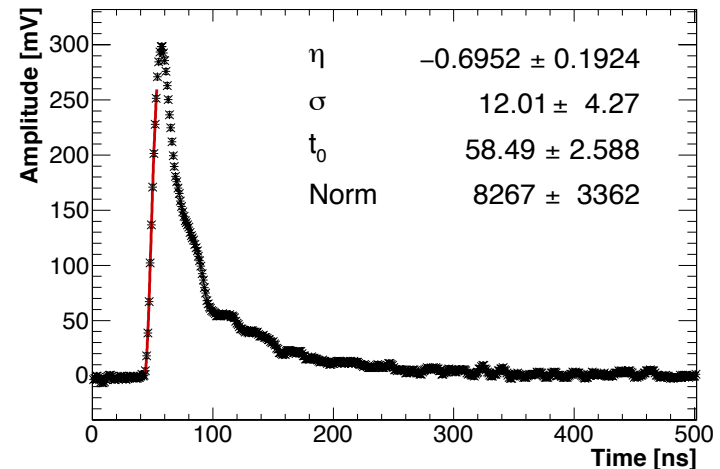
Crystal+SiPM sample between two plastic scintillation finger counters:

- TRG: counters coincidence
- Crystal wrapped with  $150\ \mu\text{m}$  Tyvek + coupled with air-gap to our 2x3 SiPM array

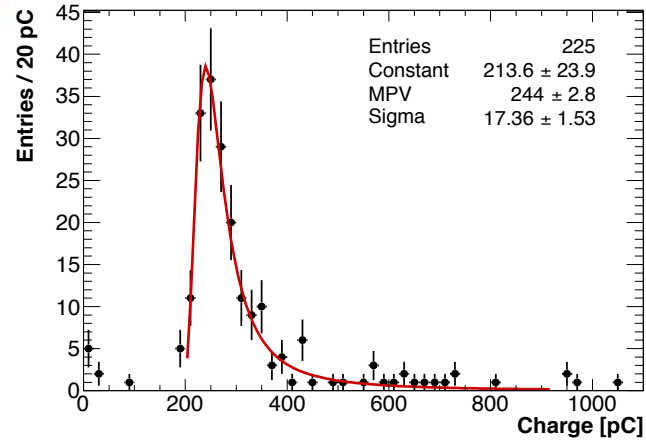
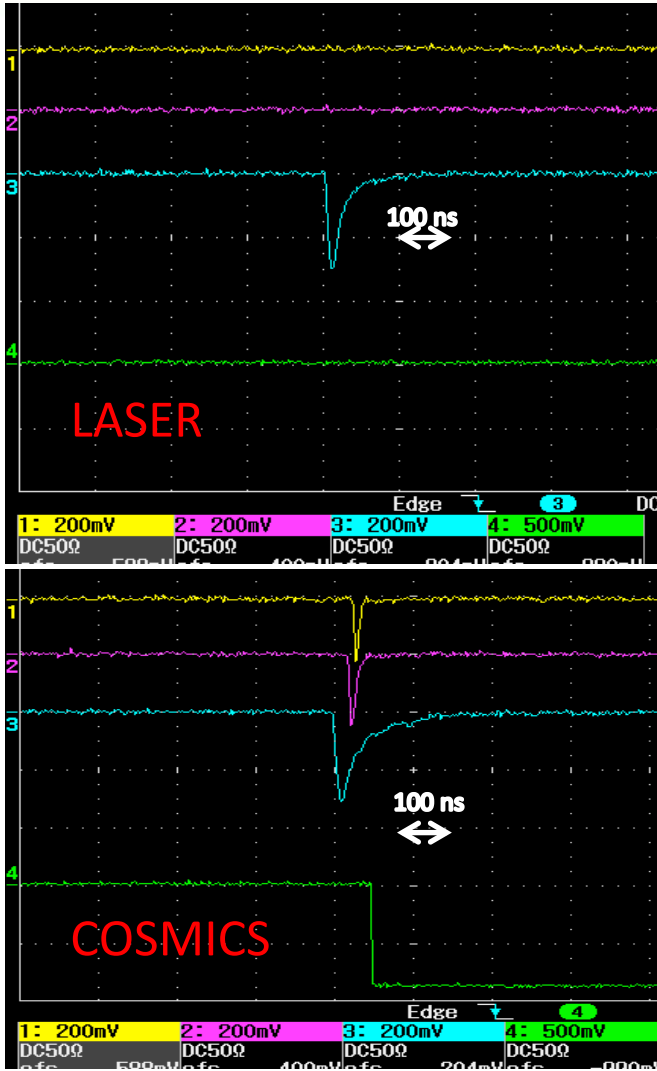


## Analysis technique

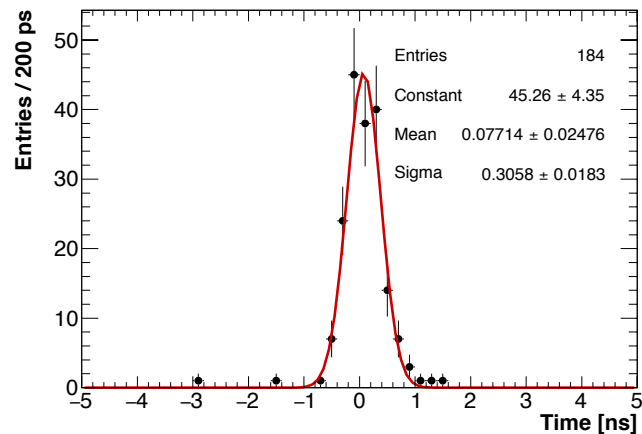
- Fit function -> **logn**
- Fit range: **(5 – 85)%** of the max amplitude (leading edge)
- Constant fraction method: best threshold 20%



# CR test of CsI+2x3 SiPM array

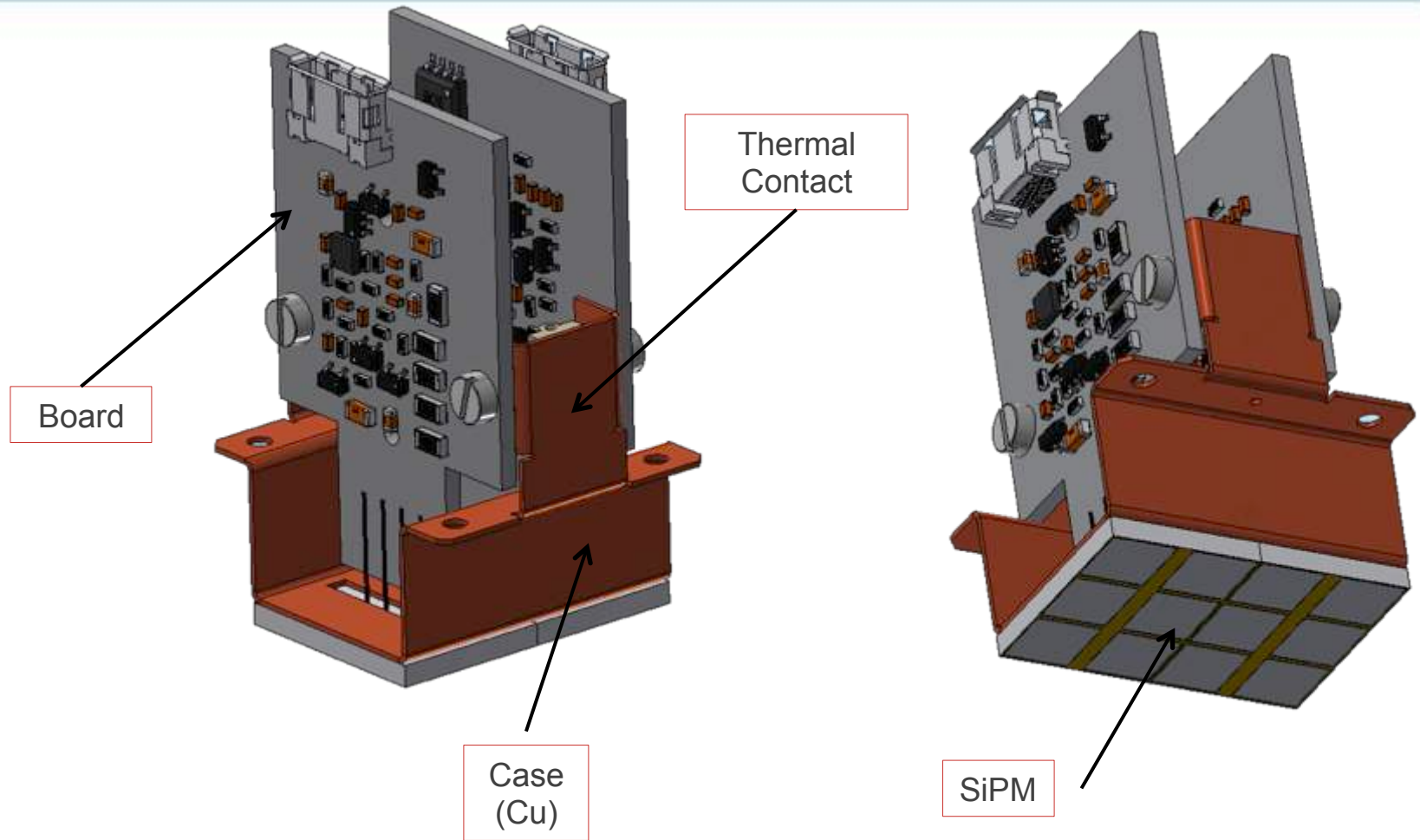


- ❖ Trigger Resolution ( $\Delta t_{\text{fingers}}$ ) = 255 ps
- ❖ Final resolution for 1 MIP ( $\sim 20$  MeV)  $\rightarrow \sim 170$  ps  
with 150  $\mu\text{m}$  Tyvek wrapping and optical coupling in air



# Engineering of the final packaging

## SiPM Holder



**Thermal conducting layer inserted in the SiPM package to cool them in vacuum (with/w.o. use of TEC Peltiers)**

# Summary

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- The silicon photomultiplier well match the requirement as a good readout for the e.m. calorimeters
  - caveat, keep the proportionality of the response ( $< 10-15\%$  of the total pixels fired)
  - Excellent time resolution
- The MPPC radiation hardness to the neutrons flux and photons dose has been investigated
  - keep the device at low temperature helps to mitigate the damage
- Three different firms appear to be capable of producing the Mu2e final SiPM thermal package (2x3 array of  $6 \times 6 \text{ mm}^2$  cells)
  - Hamamatsu, FBK and SensL



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# SPARES

# (R3) - Derived FEE/Cooling requirements

## Starting point: after 6 years of Running

We have measured, for a  $3 \times 3 \text{ mm}^2$  MPPC, a leakage current of 2.3 mA after a flux of  $2.2 \times 10^{11} \text{ n}_{-14\text{MeV}/\text{cm}^2}$  ( $4 \times 10^{11} \text{ n}_{-1\text{MeV}/\text{cm}^2}$ ) @  $25^\circ\text{C}$

→ This corresponds to 9 mA for a  $6 \times 6 \text{ mm}^2$  MPPC @  $25^\circ\text{C}$

1) Assuming a factor 2 for annealing

→ 4.5 mA per a MPPC of  $6 \times 6 \text{ mm}^2$  @  $25^\circ\text{C}$  (  $V_{op}$  )

for the proposed SiPM (matrix  $2 \times 3$  of  $6 \times 6 \text{ mm}^2$ ) we expect:

→ 9 mA for the parallel of two series @  $25^\circ\text{C}$

2) We have measured a leakage current reduction of a factor 5 operating at  $0^\circ\text{C}$

→  $9/5 = 1.8 \text{ mA}$  for the device @  $0^\circ\text{C}$

3) we can take advantage of an additional factor of 2 if needed by lowering of 0.5 V the  $V_{bias}$  with respect to  $V_{op}$  (@  $0^\circ\text{C}$  )

→  $1.8/2 = 1 \text{ mA}$  @  $0^\circ\text{C}$

at the experiment end, we will get 1 mA with 200 V of bias, 200 mW @  $0^\circ\text{C}$  ,  $V_{op}-0.5 \text{ V}$  for the innermost Layer of Disk 1 → 120 crystals → 240 photosensors

# (R4) → Operation in vacuum

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The working condition will be different working outside or inside the Detector Solenoid (DS):

- **Outside the DS:** we will run at  $\sim 20^{\circ}\text{C}$ ,  $V_{\text{bias}} = V_{\text{op}}$
- **Inside the DS:** we will run at  $\sim 0^{\circ}\text{C}$ ,  $V_{\text{bias}} = V_{\text{op}} - \text{temperature voltage coefficient}$

Each photosensor will be characterized with the QA Photosensor Station at 20, 10 and  $0^{\circ}\text{C}$  → We will know the working point for each running condition (for MPPC this corresponds to around  $50 \text{ mV}/^{\circ}\text{C}$ )

After the high radiation damage ( $> 2$  years of run), we can still work outside the DS with an under bias setting. We will check the signal with the laser sending a x10 light output.

# (R6) → Photosensor Reliability

- ❑ Determination of the MTTF requirements calculated with standalone simulation assuming independent behavior of 2 SiPMs/crystals.
- ❑ This estimate indicates the need of an MTTF of  $< 2 \times 10^6$  hours
- ❑ Existing measurement from literature indicates an MTTF for  $3 \times 3 \text{ mm}^2$  MPPCs of  $4 \times 10^6$  hours when running at  $25 \text{ }^\circ\text{C}$  (**DOI 10.1109/NSSMIC.2013.6829584**).
- ❑ Working at  $0 \text{ }^\circ\text{C}$ , we gain a reliability factor of 11 so that this translates to an **MTTF of  $44 \times 10^6$  hours**. Scaling down this result for SiPM area (x 4 i.e  $6 \times 6$  vs  $3 \times 3$ ) and number of SiPM in a Mu2e array (x 6), we have to correct by 24 → **MTTF(measured)  $\sim 1.8 \times 10^6$  hours**
- ❑ **An independent determination needed for final packaging.**  
First test underway: 4  $6 \times 6 \text{ mm}^2$  FBK SiPM in an oven at  $50 \text{ }^\circ\text{C}$   
After 1 month of running, all 4 SiPM are still perfectly OK.

# Quality Control

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- QC: Silicon Photomultipliers array – Mu2e doc-DB-7053
- The firm has to deliver devices already tested and characterized, while providing us with the following parameters for each of the two series:
  - The value of the breakdown voltage,  $V_{br}$ , and the corresponding operation voltage,  $V_{op}$ , that is around +3 V with respect to the breakdown voltage;
  - A spread on  $V_{op}$  of  $\pm 250$  mV among the different devices in the delivered batch;
  - A spread on  $V_{op}$  for the 2 series connection inside a device of  $\pm 150$  mV;
  - A gain greater than  $10^6$  at  $V_{op}$  with a spread of  $\pm 5\%$  among the different devices in the delivered batch;
  - A PDE in excess of 25% at 310 nm at  $V_{op}$ ;
  - Thermal conductivity of 20 W/(K\*m);
  - Custom package according specification drawings.

# Quality Assurance - 1 -

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- QA: Quality Assurance Procedure – Mu2e doc-DB-7053
  - Each SiPM will be dimensionally inspected to grant that the package follows pins and planarity specifications. This will be done by inserting the SiPM in a reference holder and FEE pin socket.
  - A small number of SiPM (ten) will be randomly selected for MTTF measurement. They will be operated at  $V_{op}$  in a dedicated oven at high temperature,  $55^{\circ}\text{C}$ , while illuminated with a UV LED light. When operating the SiPM at  $55^{\circ}\text{C}$ , the acceleration factor is 90, so that, with ten devices, we can extract the MTTF in around 3 months of burn-in.
  - Another small number of SiPM (five), randomly selected from the batch, will be used for radiation hardness test both with gammas and neutrons. Two of these devices will be irradiated at two different doses, 10 and 20 krad to confirm that ionization dose does not provide increase in  $I_{dark}$  or reduction of gain. These two devices can be still recovered as spare for the detector. The other three devices will be instead exposed to a neutron fluency of  $3 \times 10^{11} \text{ n/cm}^2$  (1 MeV equivalent) while kept at a thermalized temperature of  $18^{\circ}\text{C}$ . The increase of  $I_{dark}$  and the gain drop will be measured.

# Quality Assurance - 2 -

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- QA: Quality Assurance Procedure – Mu2e doc-DB-7053
  - The other 185 pieces/batch will be controlled at dedicated QA photosensor stations (one in Caltech and one in Pisa). Sharing of the load for the quality control will be 50-50 between the two stations. In these stations, we will measure, for each SiPM, at 0, 10 and 20°C: the I-V curve, the  $V_{br}$ , the gain and the relative PDE with respect to a calibrated photo-sensor.

## Configuration Management:

- Use labels with barcodes for strips and test samples
- Correlate labels with QC/QA and shipping data
- Enter data into a traveler database